

Synthesis, Characterization, and Performance of Coated Copper Nanoparticles in High Humidity and H₂S Environments



Sandia National Laboratories

Center 1800:
Material, Physical and
Chemical Sciences



PRESENTED BY

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Metal Nanoparticles have Received Great Attention for use in Numerous Applications

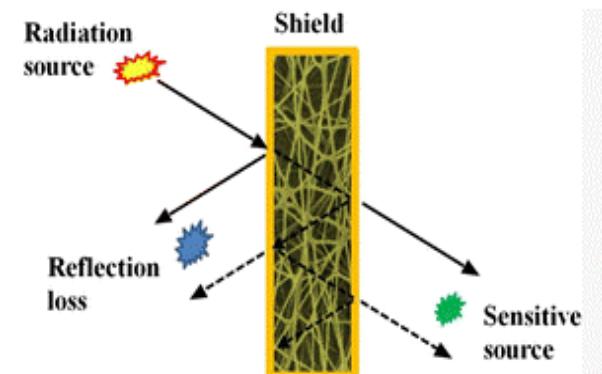
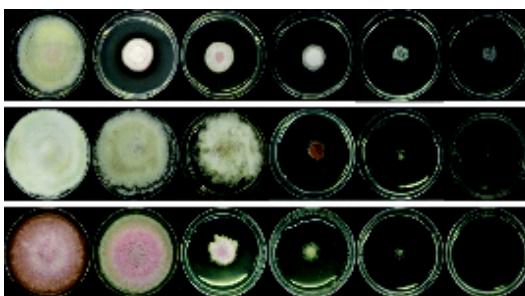
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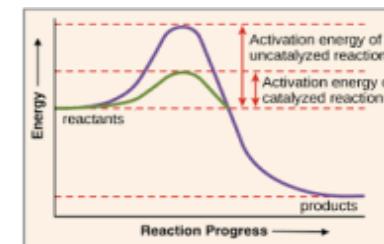
- Coinage metal nanoparticles (NP = Au⁰, Ag⁰, and Cu⁰) have been extensively researched for a wide range of application such as biosensors, optical, solar conversion, lubricants, catalysts, and additive manufacturing [1-2].
- They possess a diverse range of optical, electrical, thermal, antimicrobial, catalytic, magnetic properties that allow them to be deployed across multiple fields.
- In particular, the exceptional electrical properties silver (Ag) and gold (Au) nanoparticles (NPs) have made them the primary choice in electrical applications, but their high cost has led to the search for a more cost-effective alternative.

EMI Shielding Devices

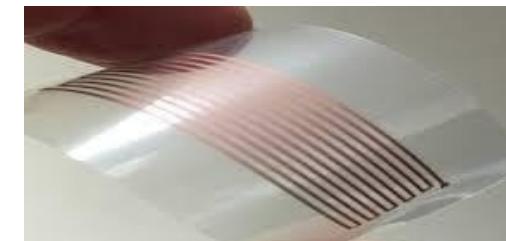
Anti-microbial and Anti-fungal agents



Catalysts



Printed Electronics

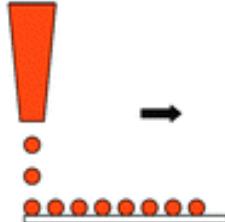
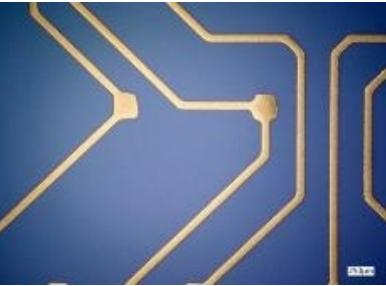


Copper is a Viable Alternative to Silver and Gold in Electronic Applications



Useful in Additive Manufacturing processes:

- Aerosol/ink-jet printing, roll-to-roll, etc.
- Electronic components: resistors, transistors, and capacitors



1	H	Hydrogen	1.008
3	Li	Lithium	6.94
4	Be	Beryllium	9.012
11	Na	Sodium	22.99
12	Mg	Magnesium	24.31
19	K	Potassium	39.09
20	Ca	Calcium	40.07
21	Sc	Scandium	44.95
22	Ti	Titanium	47.88
23	V	Vanadium	50.94
24	Cr	Chromium	51.99
25	Mn	Manganese	54.93
26	Fe	Iron	55.84
27	Co	Cobalt	58.93
28	Ni	Nickel	58.71
29	Cu	Copper	63.54
30	Zn	Zinc	65.38
5	B	Boron	10.81
6	C	Carbon	12.01
7	N	Nitrogen	14.01
8	O	Oxygen	15.98
9	F	Fluorine	18.98
10	Ne	Neon	20.18
13	Al	Aluminum	26.98
14	Si	Silicon	28.09
15	P	Phosphorus	30.97
16	S	Sulfur	32.06
17	Cl	Chlorine	35.45
18	Ar	Argon	39.94
29	Cu	Copper	63.546
30	Zn	Zinc	65.40
31	Ga	Gallium	69.72
32	Ge	Germanium	72.63
33	As	Arsenic	74.93
34	Se	Selenium	78.97
35	Br	Bromine	79.98
36	Kr	Krypton	83.79
37	Rb	Rubidium	88.90
38	Sr	Samarium	89.82
39	Y	Yttrium	88.90
40	Zr	Zirconium	91.22
41	Nb	Niobium	92.91
42	Mo	Molybdenum	95.94
43	Tc	Techneium	97.90
44	Ru	Ruthenium	101.09
45	Rh	Rhodium	102.91
46	Pd	Palladium	106.42
47	Ag	Silver	107.87
48	Cd	Cadmium	112.41
49	In	Inium	113.48
50	Sn	Tin	118.71
51	Sb	Antimony	121.76
52	Te	Tellurium	127.60
53	I	Iodine	126.90
54	Xe	Xenon	131.29
55	Cs	Cesium	132.91
56	Ba	Barium	137.32
57	Lu	Lutetium	174.97
58	Hf	Hafnium	180.91
59	Ta	Tantalum	182.94
60	W	Tungsten	183.83
61	Re	Rhenium	186.20
62	Os	Osmium	190.23
63	Ir	Iridium	192.23
64	Pt	Ptodium	195.08
65	Au	Aurum	196.97
66	Hg	Mercury	200.53
67	Tl	Thallium	204.41
68	Pb	Lead	207.23
69	Bi	Bismuth	208.98
70	Po	Polonium	209.00
71	At	Astatine	210.22
72	Rn	Radon	222.22
73	Lu	Lutetium	174.97
74	Hf	Hafnium	180.91
75	Ta	Tantalum	182.94
76	W	Tungsten	183.83
77	Re	Rhenium	186.20
78	Os	Osmium	190.23
79	Ir	Iridium	192.23
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81	Au	Aurum	196.97
82	Hg	Mercury	200.53
83	Tl	Thallium	204.41
84	Pb	Lead	207.23
85	Bi	Bismuth	208.98
86	Po	Polonium	209.00
87	Fr	Francium	223.02
88	Ra	Radium	226.02
89	Lr	Lanthanum	138.90
90	Rf	Rutherfordium	140.12
91	Db	Dubnium	141.35
92	Ta	Tantalum	182.94
93	Pa	Protactinium	145.91
94	U	Uranium	141.92
95	Np	Neptunium	144.24
96	Pu	Plutonium	147.53
97	Am	Americium	149.15
98	Cm	Cerium	149.96
99	Bk	Berkelium	147.25
100	Cf	Cfetium	149.30
101	Es	Einsteinium	149.53
102	Fm	Fermium	149.97
103	Md	Mendelevium	152.51
104	No	Nothrium	152.91

*Lanthanide series
La Lanthanum
Ce Cerium
Pr Praseodymium
Nd Neodymium
Pm Promethium
Sm Samarium
Eu Europium
Gd Gadolinium
Tb Thulium
Dy Dysprosium
Ho Holmium
Er Erbium
Tm Thulium
Yb Ytterbium

** Actinide series
Ac Actinium
Th Thorium
Pa Protactinium
U Uranium
Np Neptunium
Pu Plutonium
Am Americium
Cm Cerium
Bk Berkelium
Cf Cfetium
Es Einsteinium
Fm Fermium
Md Mendelevium
No Nothrium

SQ: How can copper oxidation be mitigated?

Advantages of Copper?

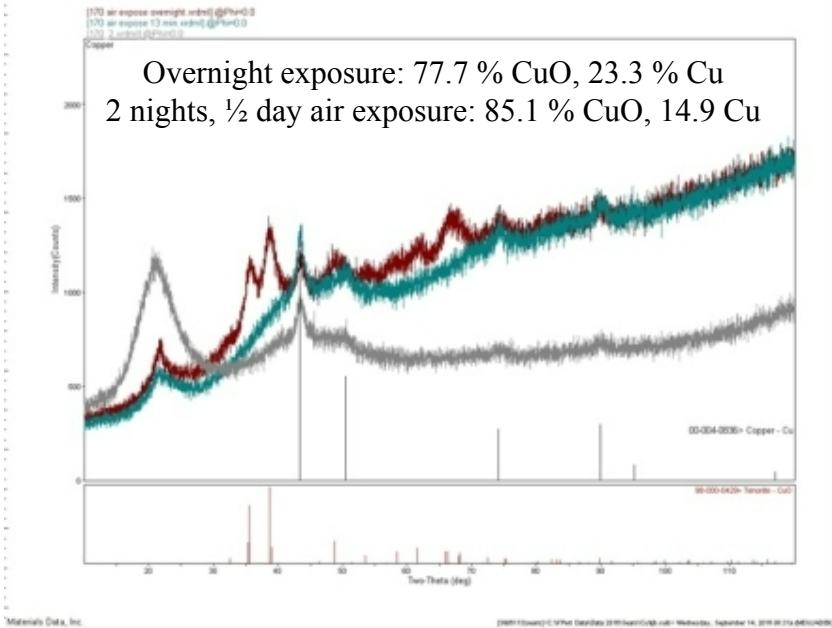
- Exceptional electrical and thermal conductor
- Cheaper option compared to other metals, such as gold and silver
- $\text{Cu} = 0.18 \text{ USD} < \text{Ag} = 23.48 \text{ USD} < \text{Au} = 1962.55 \text{ USD}$ per troy ounce
- Cu is 130x cheaper than Ag and 11,000x cheaper than Au!

Disadvantages of Copper?

- Intrinsic sensitivity to oxidation under atmospheric conditions
- Susceptible to corrosion



Overnight exposure: 77.7 % CuO, 23.3 % Cu
2 nights, ½ day air exposure: 85.1 % CuO, 14.9 Cu

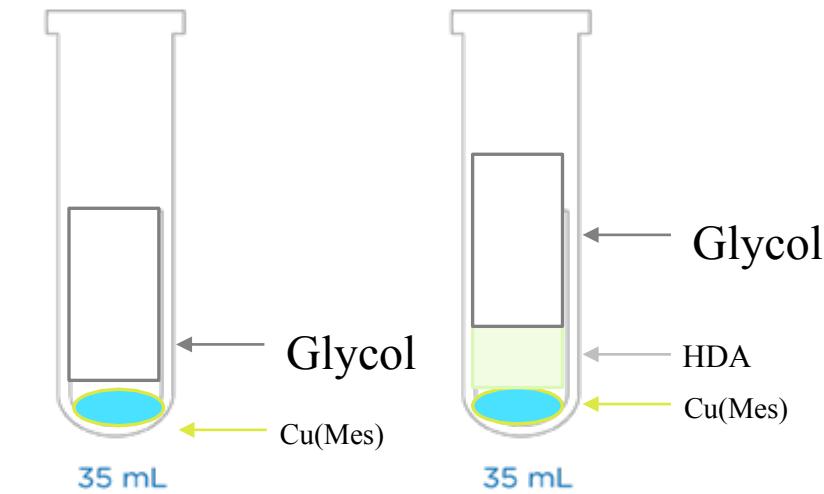
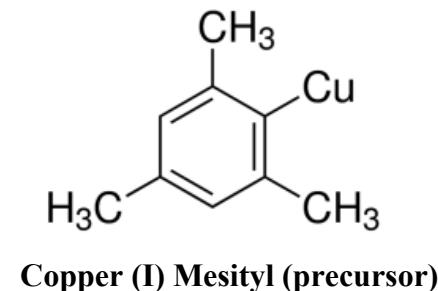
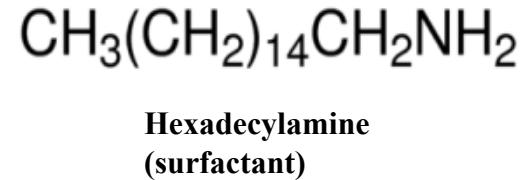
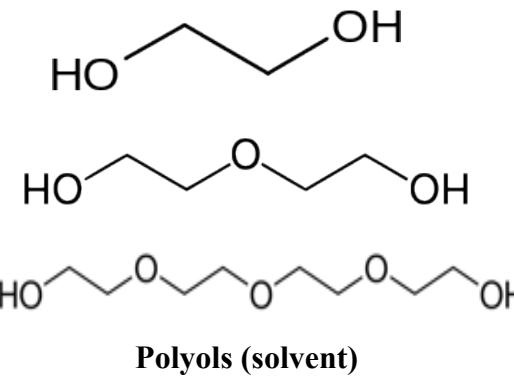


CuO observed as early as overnight exposure to air

Surface Protection Through the Use of Green Surfactants



- Several attempts and concepts have been deployed to increase the oxidation resistance of Cu NPs by the addition of various compounds to serve as surfactants.
- Alkylamines (with various lengths), polyols, alkanethiols, allylamine, polyallylamine, and polyvinylpyrrolidone (PVP) have been used in previous research as surfactants for Cu NPs.
- Amine-based ligands such as oleylamine, hexadecylamine, benzotriazole, etc. have high affinity for Cu (111) surfaces and have been shown to provide exceptional oxidation resistance.
- Ligand–NP surface interaction can affect growth rates, morphology, and colloidal stability.
- Glycols preferable because of use as reducing agent, microwave activity, environmentally friendly.

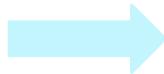


SQ: How do glycols and amines affect the production and protection of Cu-NPs?

Experimental Flow Chart



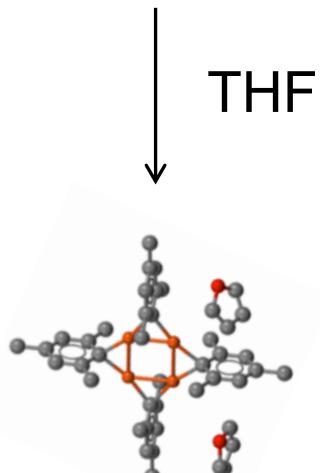
Precursor



Cu(Mes)

- Easily decomposable
- Environmentally friendly

$\text{CuCl} + \text{Mg}(\text{Mes})\text{Br}$



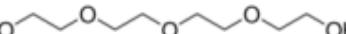
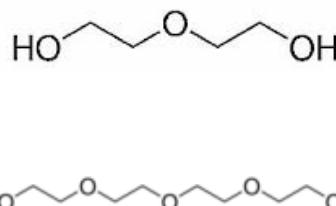
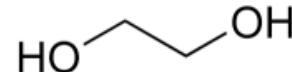
Boyle's Group

Solvent/ Surfactant



Polyols

- Inexpensive
- Microwave active
- Reducing agent

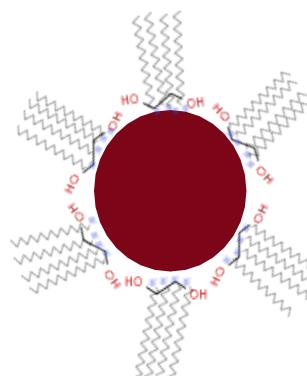


Surfactant



Provide NP Protection

- Oxidation resistance
- Agglomeration
- Ink performance
- Conductivity
- Reproducibility



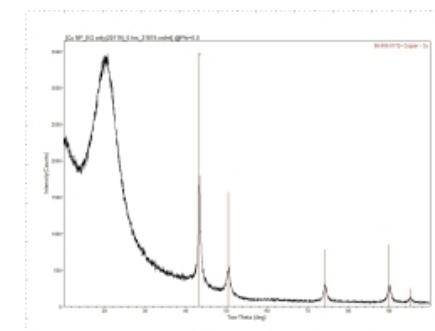
Environmental Testing



Characterization

Techniques (inert vs air)

- PXRD
- TEM
- FTIR
- TGA
- FACT-testing (Cl_2 , NO_x , etc)



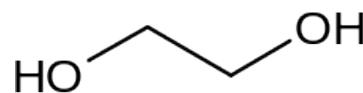
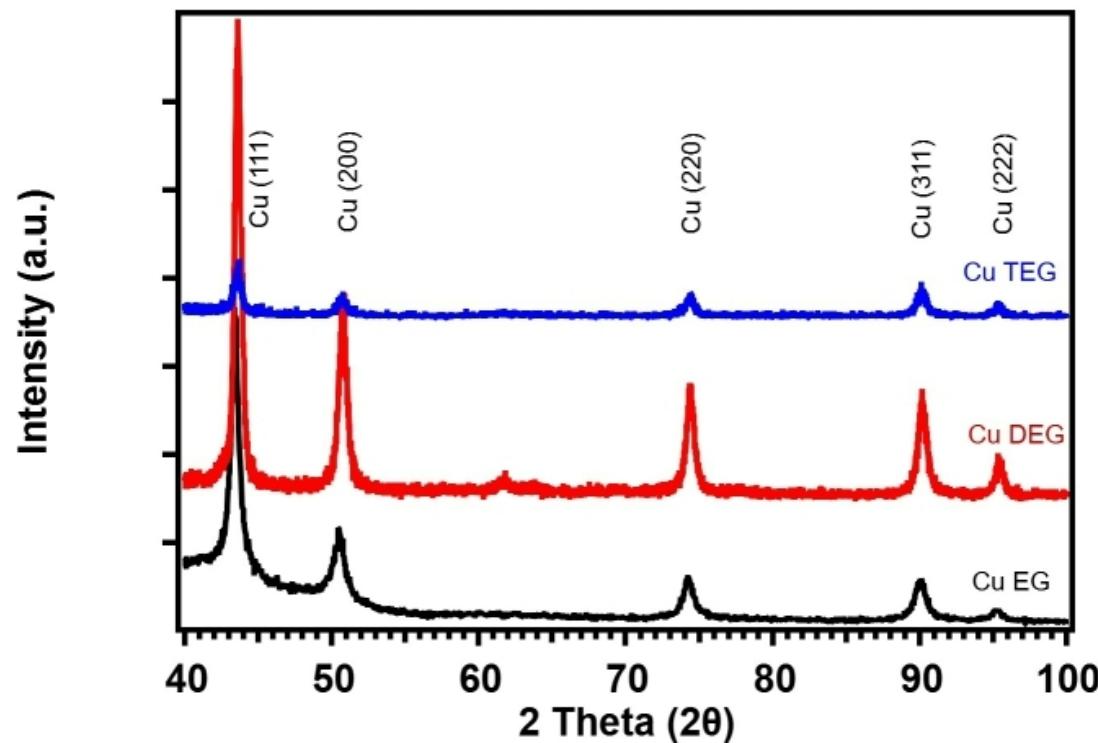
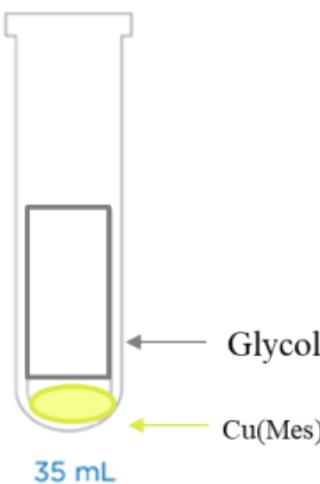
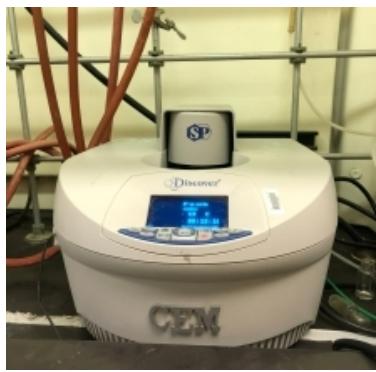
Printing (Future Work)



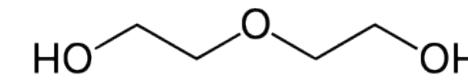
*3D printing
oxidation resistant
nanoparticle*



Understanding the Role of the Glycol Reactive Sites/Lengths on Cu-NPs



Ethylene glycol (EG)



Diethylene glycol (DEG)



Tetraethylene glycol (TEG)

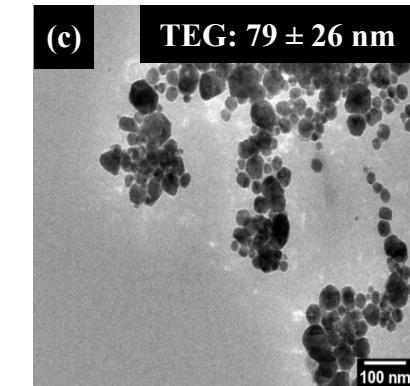
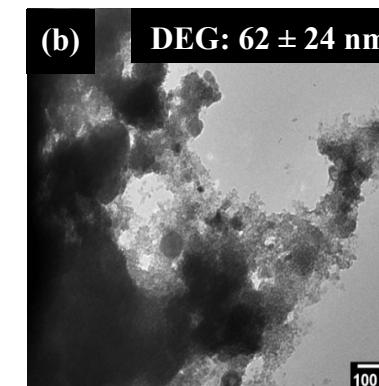
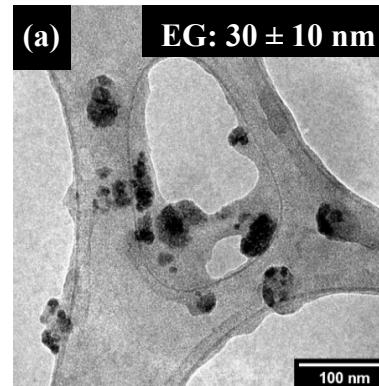
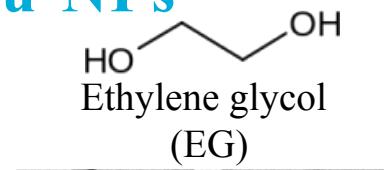
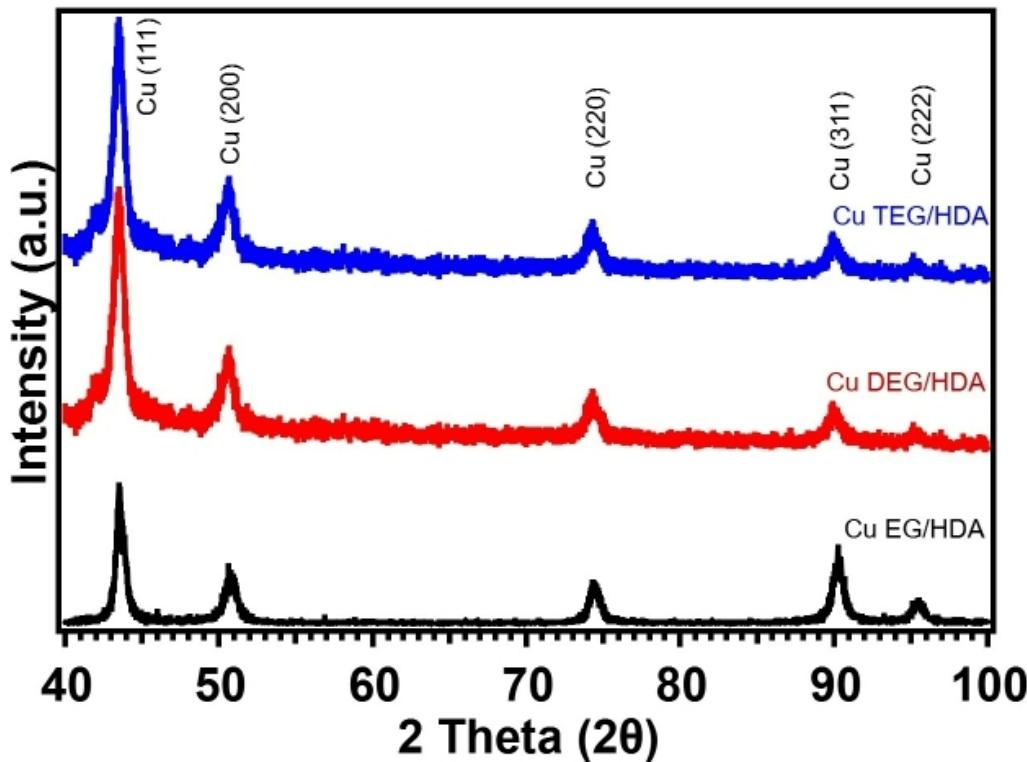
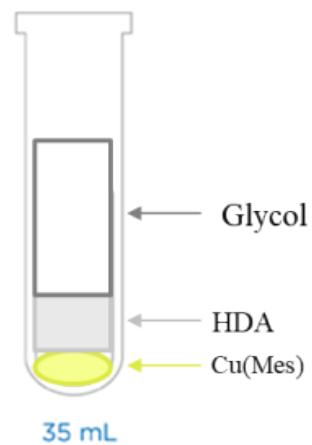
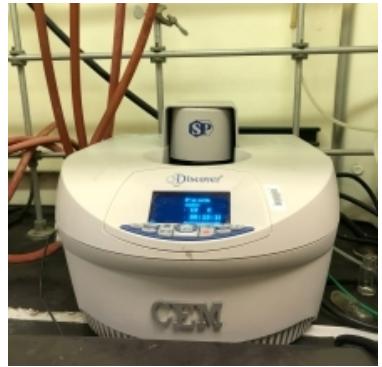


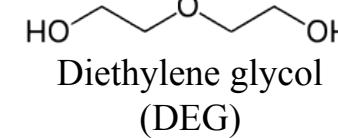
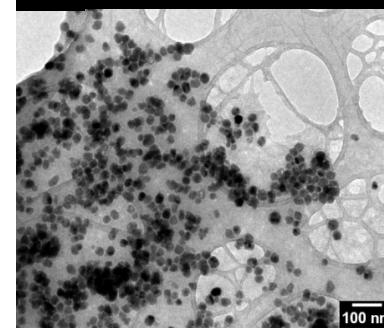
Figure 1. TEM images of Cu NPs synthesized with (a) EG, (b) DEG, and (c) TEG.

- x Glycol-Cu-NPs exhibit irregular shapes and large size distributions NPs.
- x As the glycol length increases, the particle size and deviation also increase.

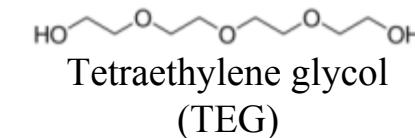
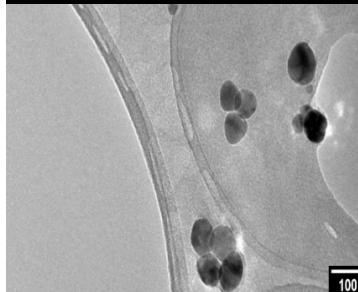
Understanding the Role of the Glycol Reactive Sites/Lengths + HDA on Cu-NPs



(a) EG/HDA: 10 ± 3 nm



(b) DEG/HDA: 30 ± 5 nm



(d) Cu/HDA: 25 ± 2 nm

(c) TEG/HDA: 14 ± 2 nm

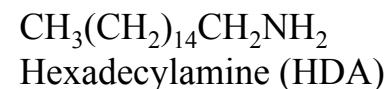
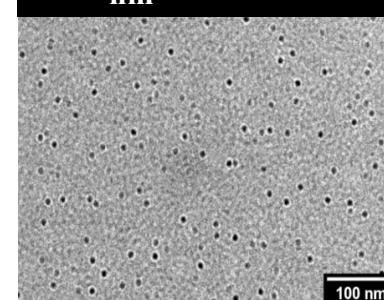


Figure 2. TEM images of Cu NPs synthesized with (a) EG/HDA, (b) DEG/HDA, (c) TEG/HDA, and (d) Cu/HDA

- ✓ Glycol/HDA-Cu-NPs yielded monodispersed and spherical particles with small size distribution.
- ✓ Amines bind to a specific facet of the Cu-NPs that enable the growth of spherical nanoparticles with or without glycol presence.
- ✓ NPs synthesized with only HDA present also yielded spherical Cu-NPs with small size.

FTIR & TGA of As Synthesized Cu NPs w/wo HDA

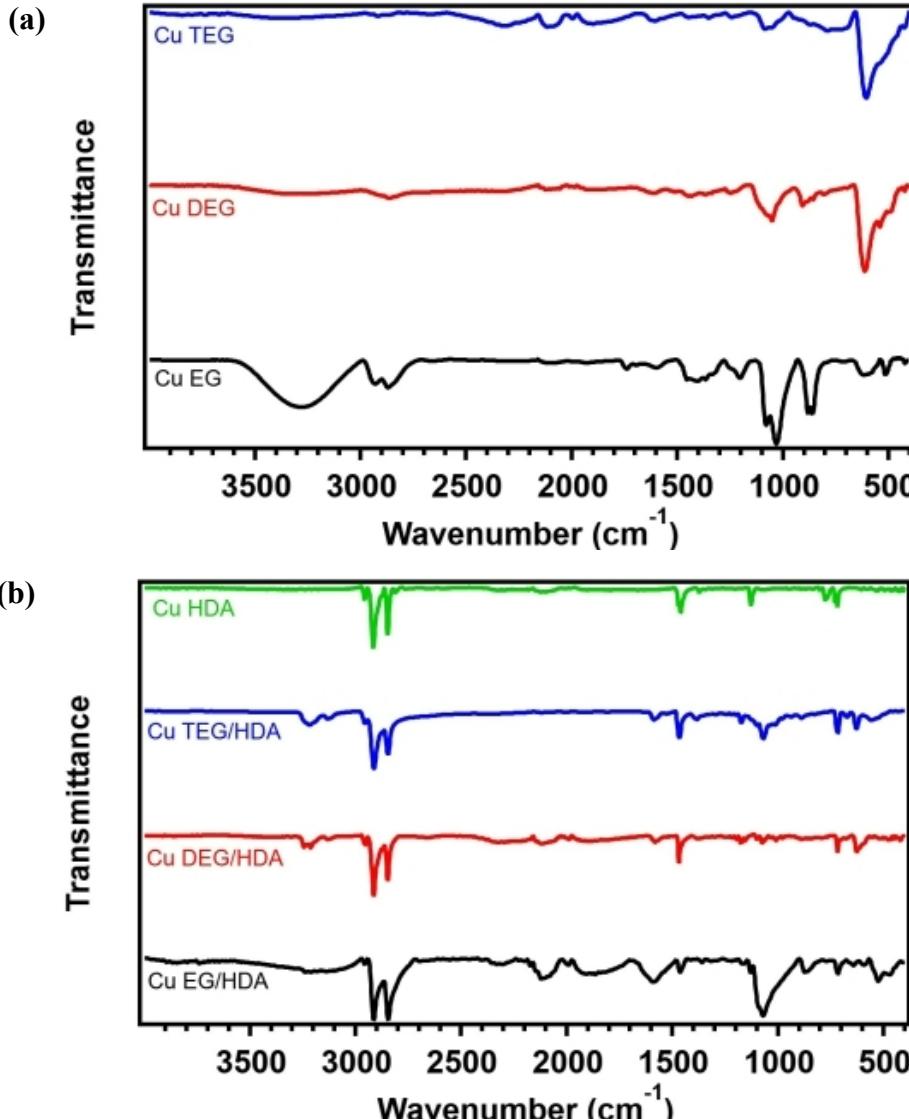


Figure 3. (a) FTIR spectra of Cu NPs synthesized with EG, DEG, PG, and TEG. (b) FTIR spectra of Cu NPs synthesized with EG+HDA, DEG+HDA, PG+HDA, and with TEG+HDA.

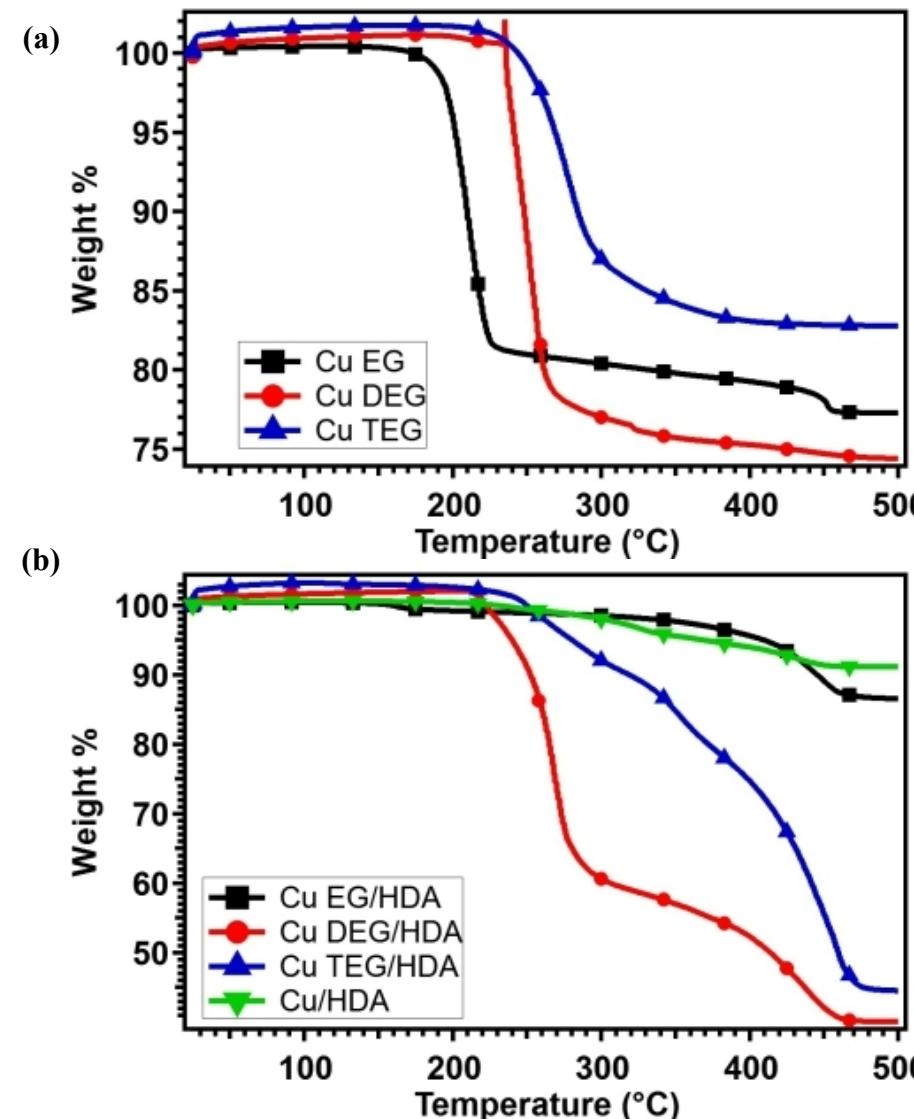
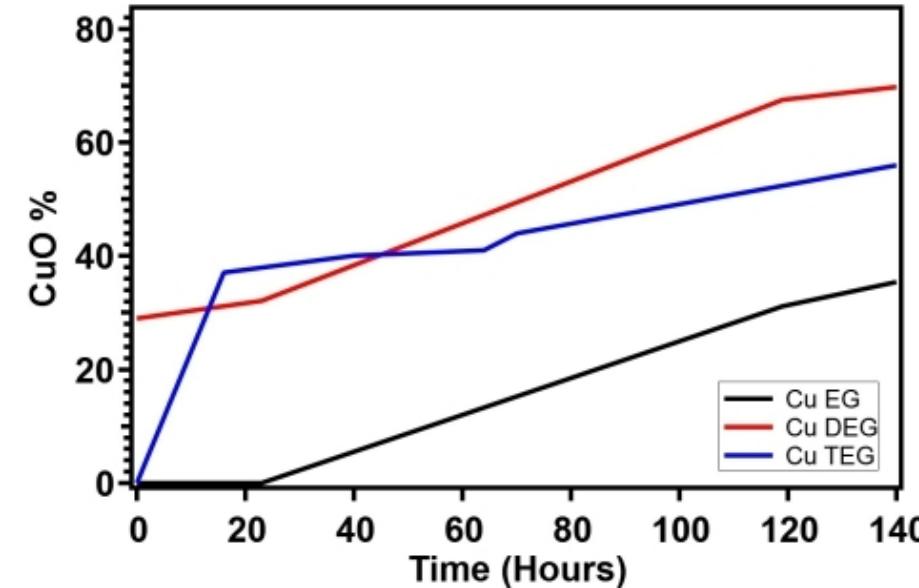
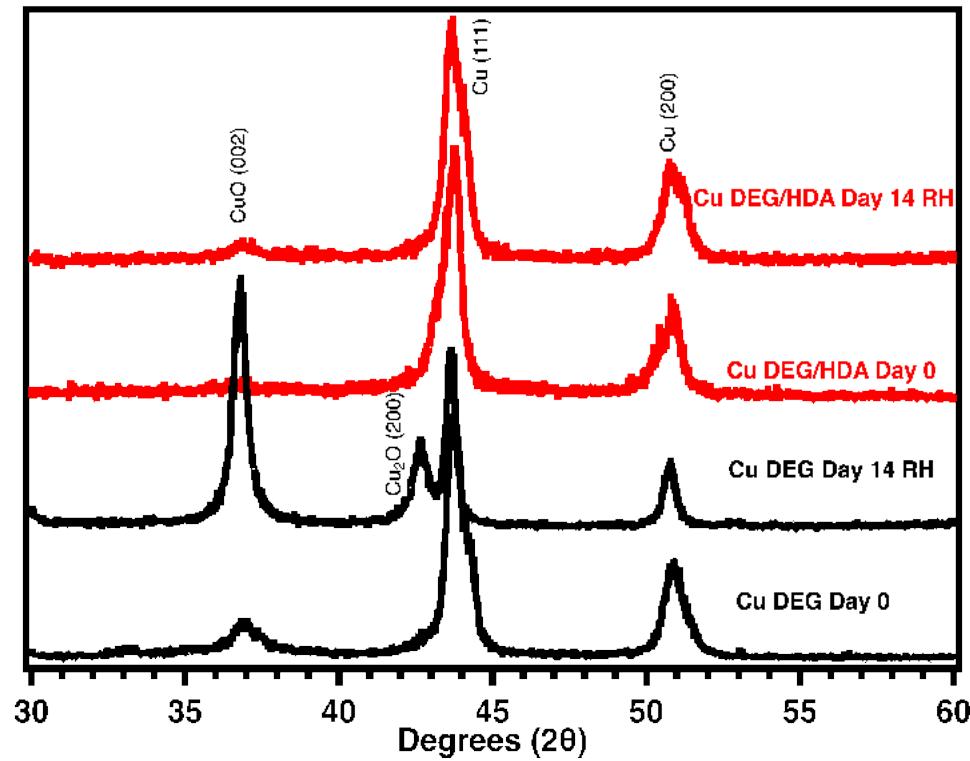


Figure 4. TGA spectra of Cu-NPs synthesized with only glycol (a) and Cu-NPs synthesized with glycol and HDA (b).

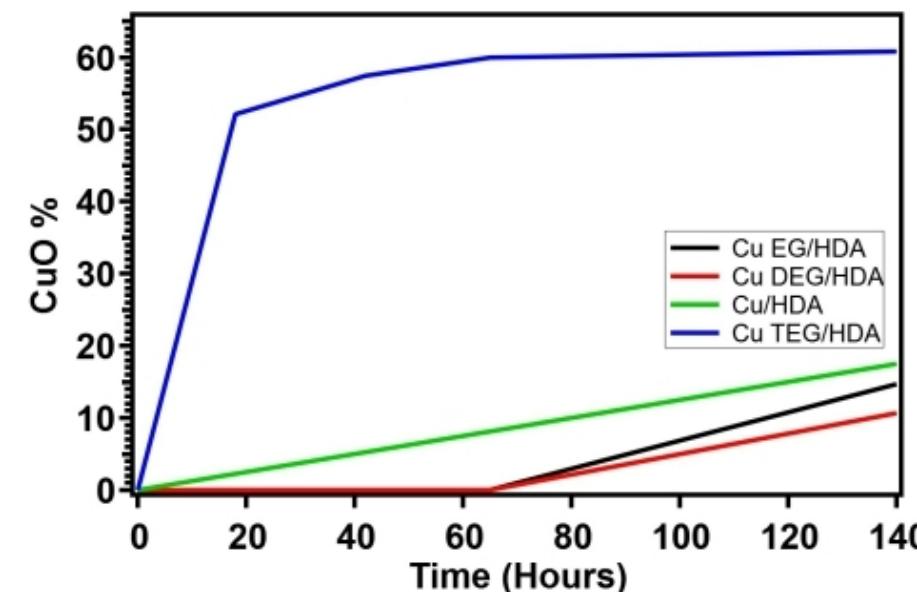
Cu-NP in 100% RH Environment for 14 Days



Normalized Intensity



GES System for Environmental Testing



- ✓ PXRD indicates that the combination of the glycol and HDA, gives the Cu-NPs much higher resistance to oxidation in high humidity.
- Glycols have exceptional coating performance of Cu-NPs, but their miscibility in water could lead to poor oxidation protection.
- HDA on the other hand is extremely hydrophobic which can prove beneficial in preventing water from reaching the Cu-NP surface.

Periodic DFT for Cu (111) surface, DEG, HDA, and H₂O Interactions



- DEG has a consistent binding energy (BE) with the Cu (111) surface at both concentrations.
- For the HDA, the BE is stronger at higher concentrations (-1.27 eV) and weaker at lower concentrations.
- In solutions where both HDA and DEG molecules are present, initial binding will be between the Cu(111) surface and the HDA up to $\sim 0.1 \text{ #}/\text{nm}^2$, and then subsequent DEG binding.
- This supports the results from TEM, FTIR, and oxidation studies indicating that for Glycol/HDA-Cu-NPs, binding of HDA first, followed by subsequent binding of the glycol occurs.

Table 1: Binding energy (eV) between the surfactant (HDA or DEG) and the Cu(111) surface

Surfactant	Concentration (#/nm ²)	Binding Energy (eV)	
		Surfactant to Cu (111)	Surfactant to Surfactant
DEG	0.1	-0.727	
	0.2	-0.715	
HDA	0.1	-1.273	
	0.2	-0.534	

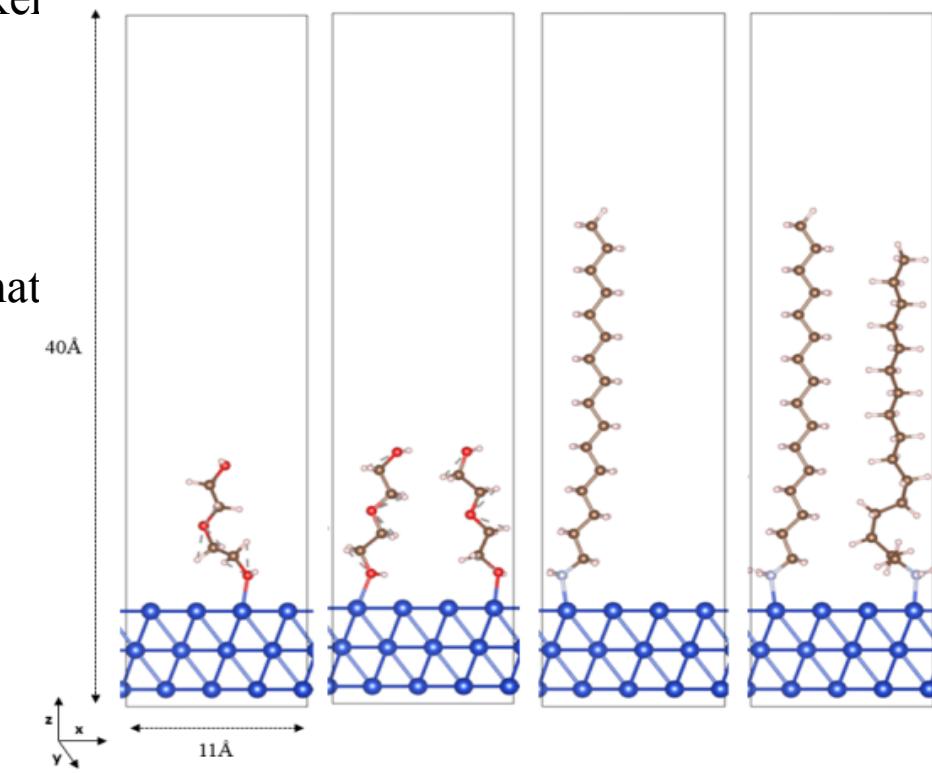


Figure 5. DFT structural models for (111) Cu surface with either one or two DEG and HDA molecules. Colors: copper (royal blue), carbon (grey), oxygen (red), hydrogen (white), nitrogen (light blue).

Periodic DFT Explains Synergistic Surfactant Oxidation Performance of Cu-NPs



- With any surfactant present, a clear increase in BE is observed when the H_2O molecules need to pass through the surfactant to access the surface, an effect which was more clear on the Cu(111) surfaces with higher surfactant concentration.
- For example for the Cu(111) surface with 0.2 HDA/nm² there was a increase in binding energy by ~0.2 eV, when the water molecule passes the surfactant molecule (~15 Å from the surface).
- While this only represents an initial investigation into the HDA/DEG terminated Cu(111) surface, it does demonstrate that there is some interaction between the HDA/DEG that is protective of bare Cu surfaces in the presence of water.
- Overall, the water molecules bound more strongly to the bare Cu(111) surface than to the surface with the surfactant present, with energy penalties between 0.03-0.36 eV.

Table 2: Binding energy (eV) between the surfactant (HDA/DEG) and the Cu(111) surface and in the presence of water.

Surfactant	Concentration (#/nm ²)	H ₂ O to Cu (111)+Surfactant	
		Surfactant only	Surfactant + H ₂ O
DEG	0.1		-1.25
	0.2		-1.51
HDA	0.1		-1.30
	0.2		-1.06

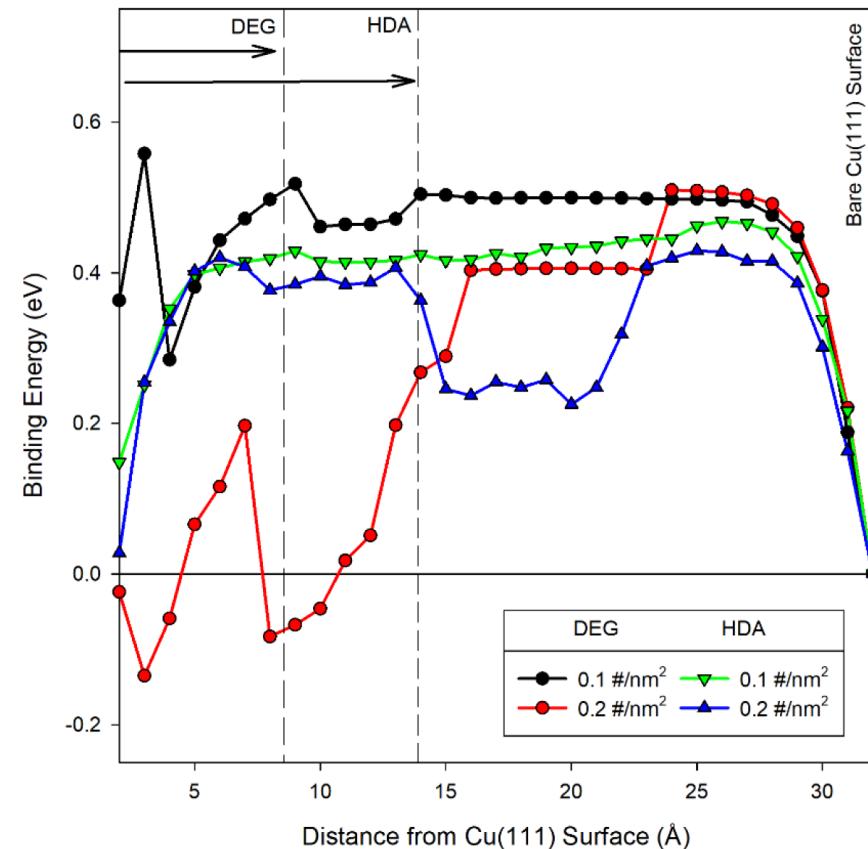
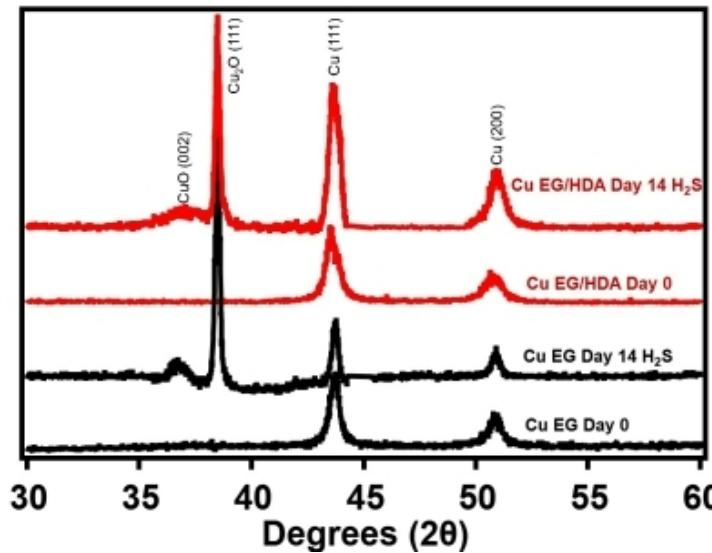


Figure 6. Binding energy (eV) of water with a Cu(111) with either 0.1 #/nm² or 0.2 #/nm² surfactant molecules bound to the surface.

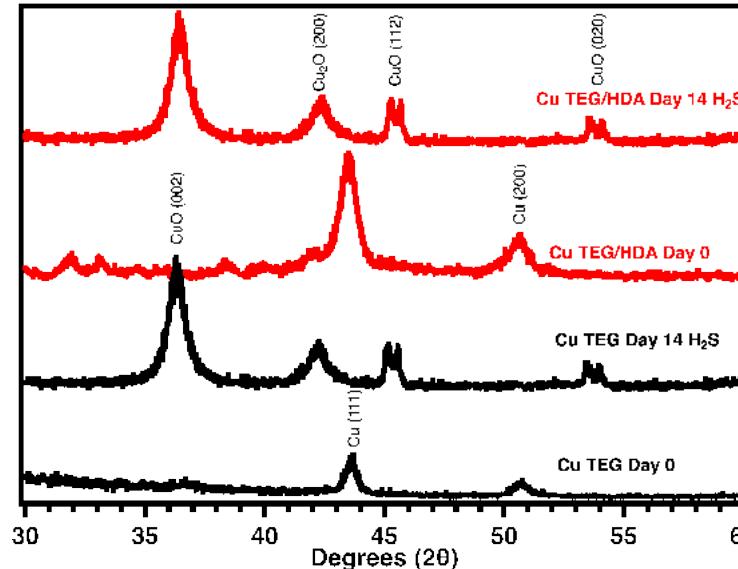
Cu-NP in 10 ppm H₂S/50% RH Environment for 14 Days



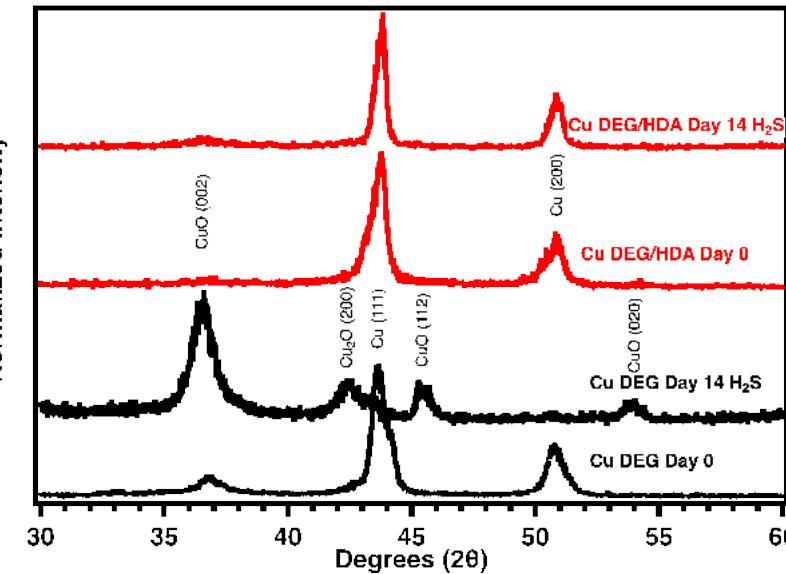
Normalized Intensity



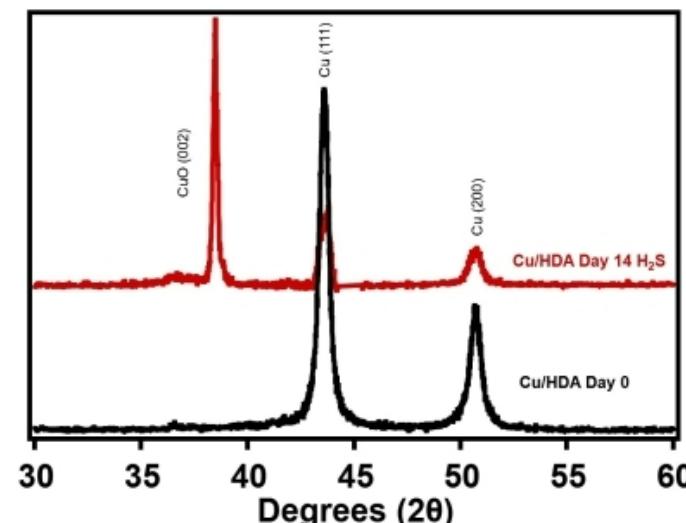
Normalized Intensity



Normalized Intensity



Normalized Intensity

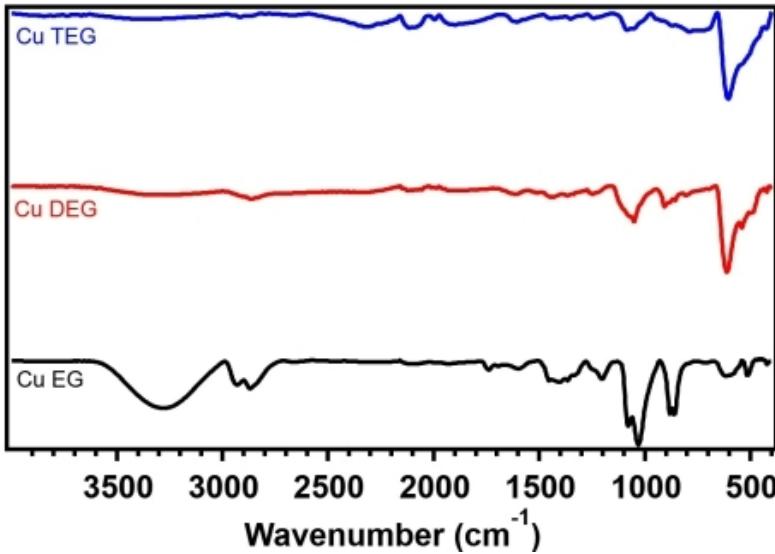


*GES System for
Environmental Testing*

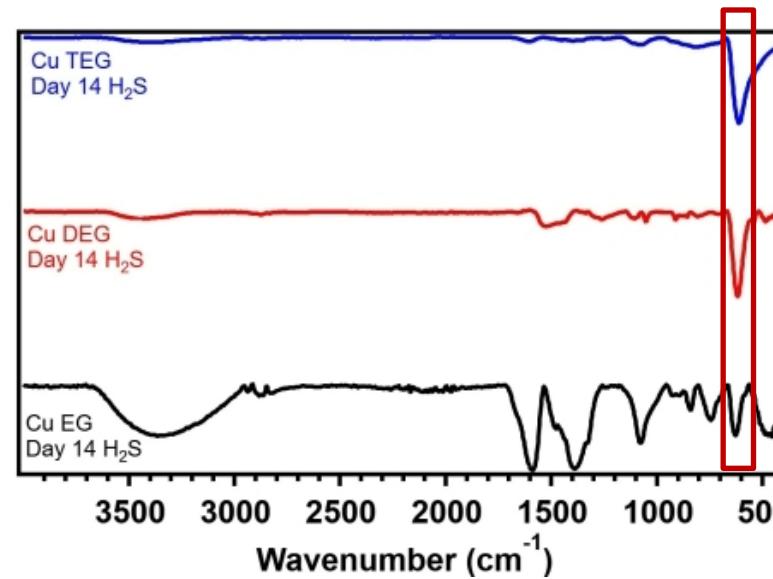
Sample	Cu %
Cu DEG	20
Cu DEG/HDA	77.6
Cu TEG	25.1
Cu TEG/HDA	46.6
Cu/HDA	33

FTIR of Cu-NPs after H_2S Exposure

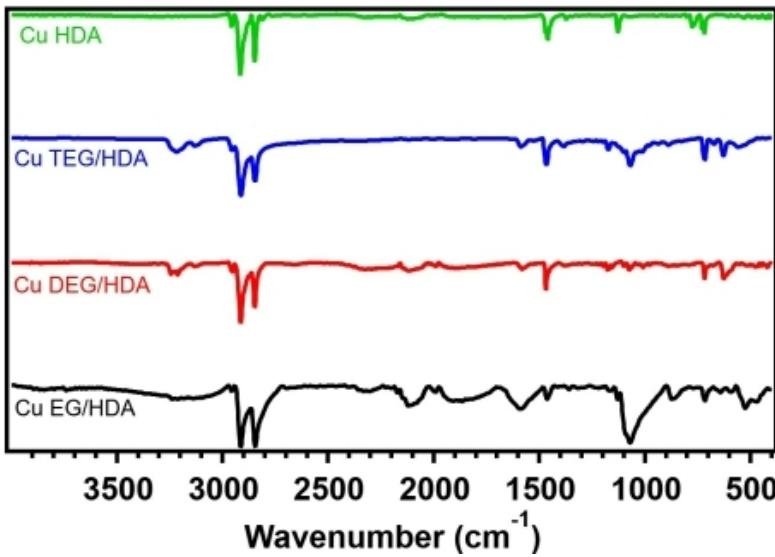
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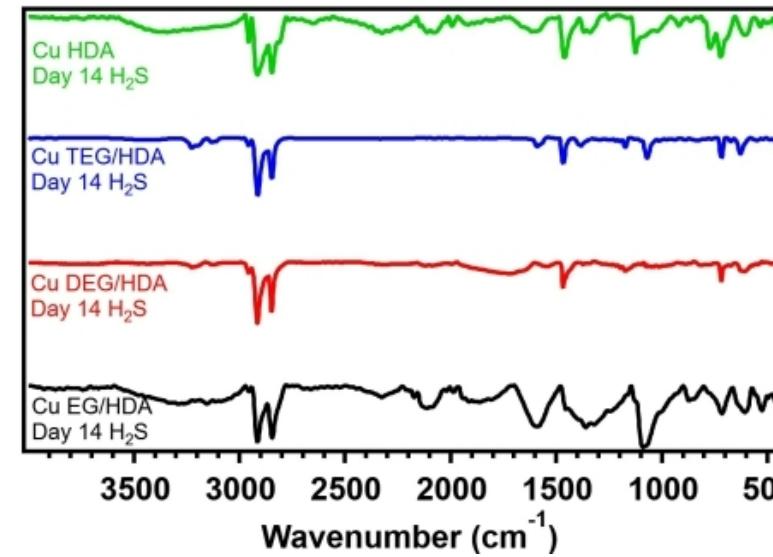
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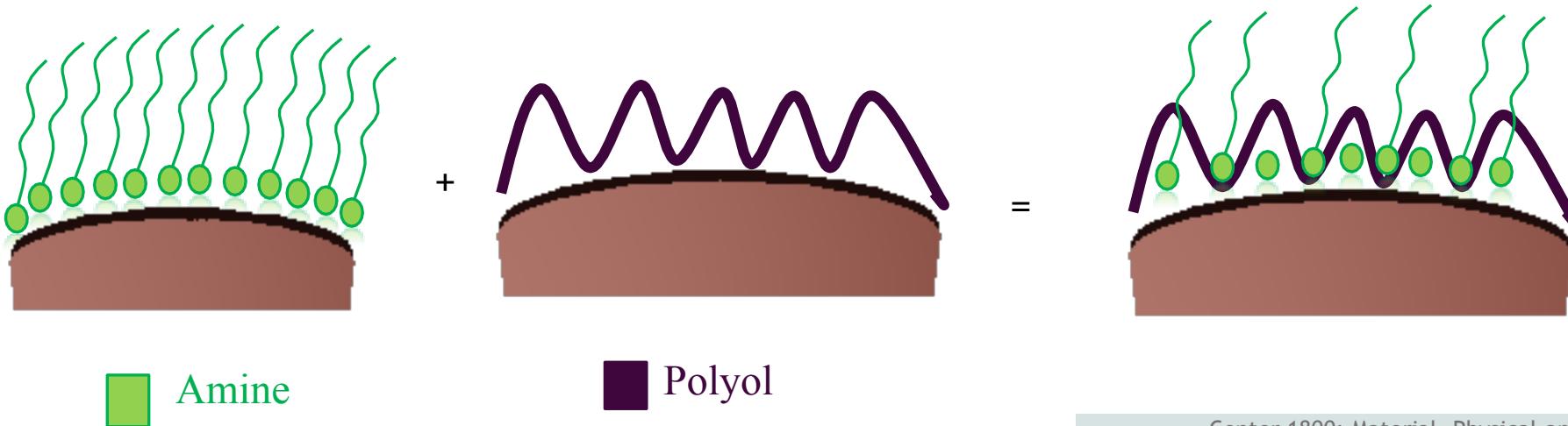
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- Glycol-Cu-NPs show strong peaks near 600 cm^{-1} , which are associated with Cu-O bonding (denoted by red box).
- Their increase in intensity over time supports oxidation of the Cu NP surface.
- This peak behavior isn't seen in polyol/HDA particles.

Conclusion

- ✓ A novel Cu-NP synthesis recipe via a microwave-assisted polyol method was developed.
- ✓ This recipe was also modified to synthesize oxidation-resistant Cu nanoparticles via the addition of HDA during the synthesis procedure.
- ✓ FTIR & TGA show the surface chemistry of the Cu-NPs indicating both species being present.
- ✓ The synergistic effects between the coating performance of the polyol and the hydrophobic properties of HDA leads to exceptional overall oxidation resistance in harsh environments.
- ✓ While O_2 adsorption on (111) oriented fcc Cu surface is thermodynamically favorable, amines have been shown to have an exceptional affinity to the same (111) surfaces.
- ✓ Overall, cost effective, oxidation-resistant copper nanoparticles were able to be quickly synthesized and efficiently.



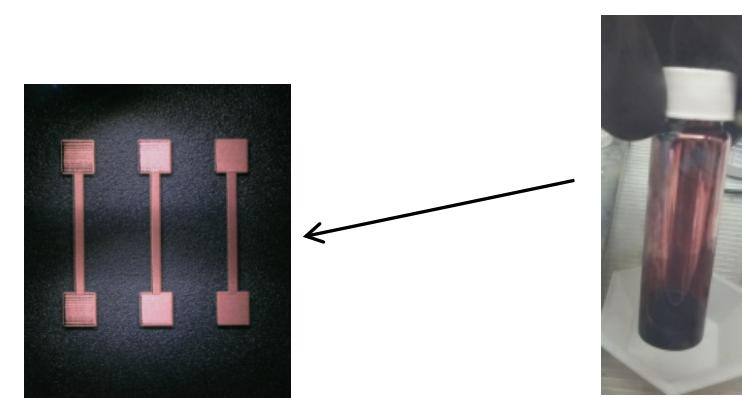
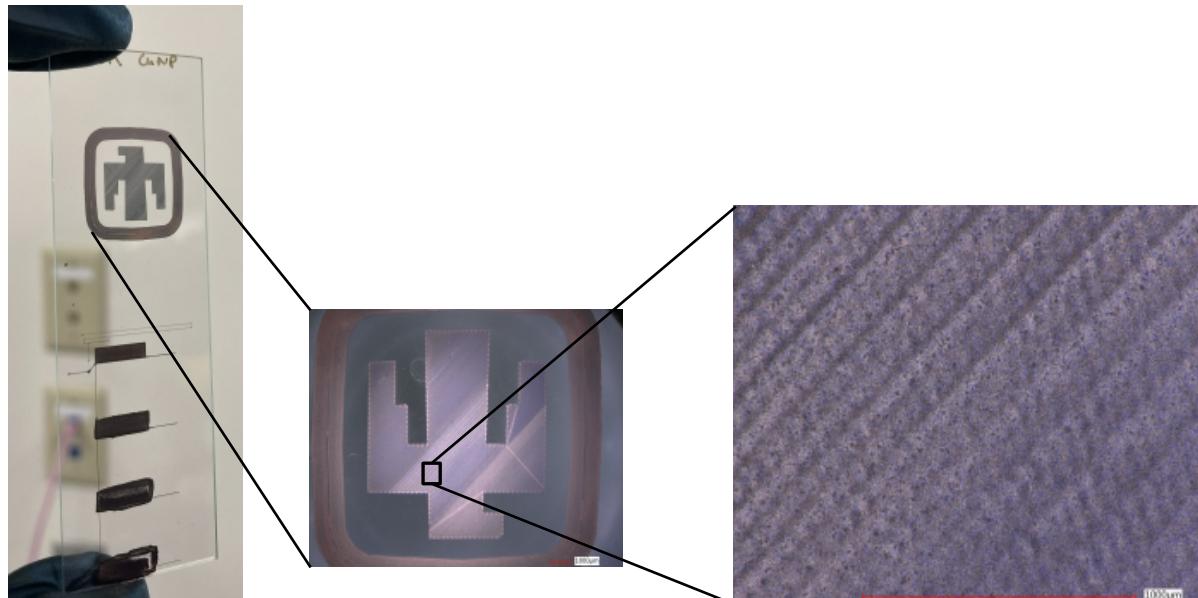
Future Work

Goal:

- Printable and conductive ink with homogenous distribution
- Easily dispersed in solution
- Able to be sintered

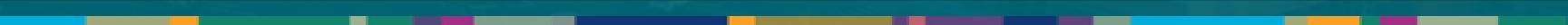
Current Status:

- Able to aerosoljet print Cu NP inks
- Currently optimizing ink performance to be comparable to bulk Cu
- Best performing ink is 54x bulk Cu





QUESTIONS?

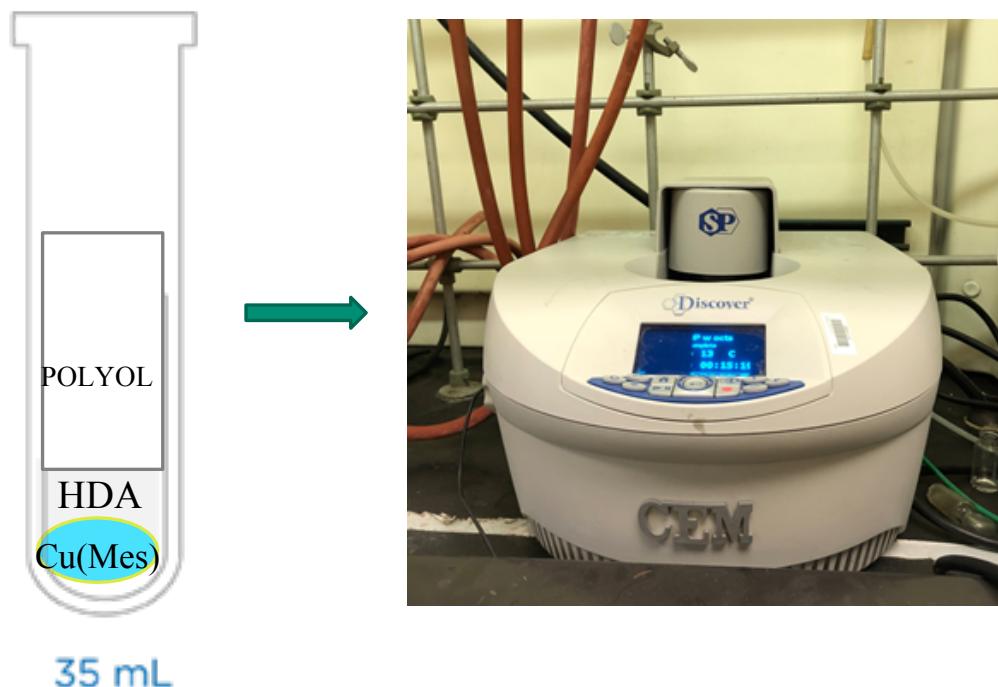
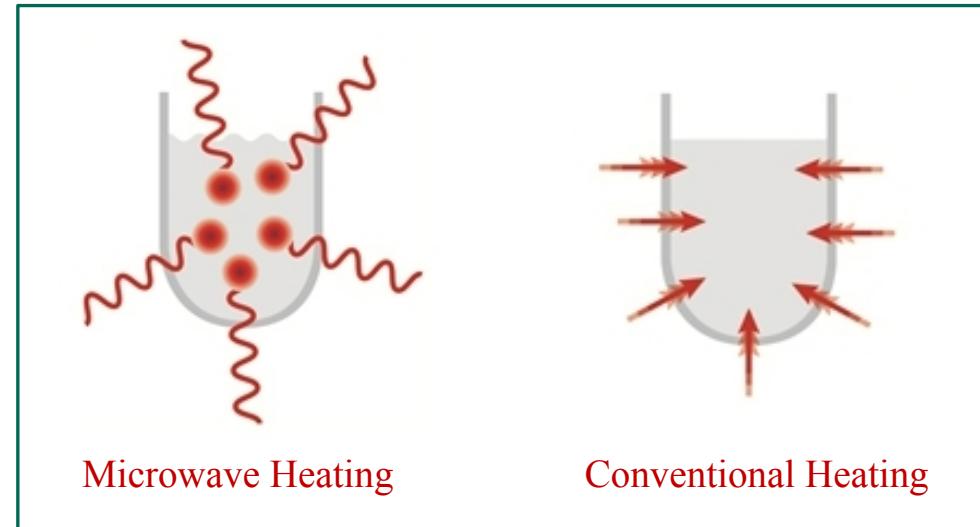


Microwave Synthetic Route for Cu NP Production



Benefits of microwave heating:

- Direct interaction with materials
- Increased reaction rate
- Milder reaction conditions
- Greater chemical yield
- Rapid synthesis
- Uniform heating

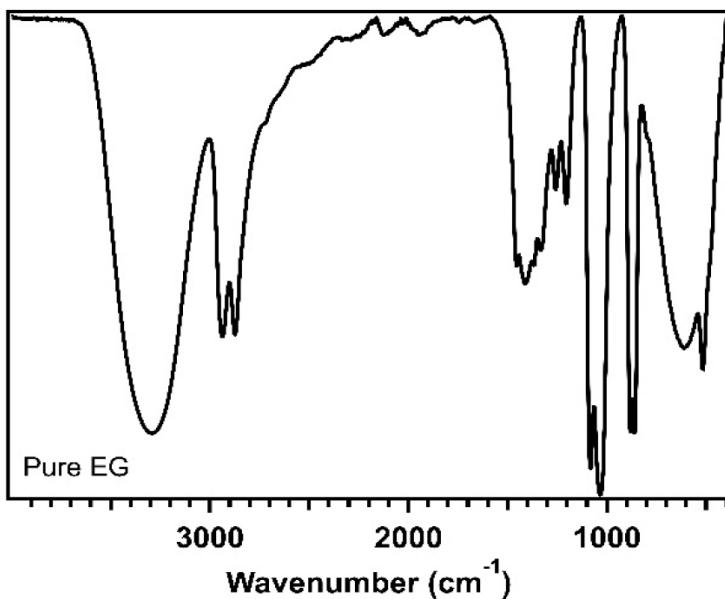


Procedure:

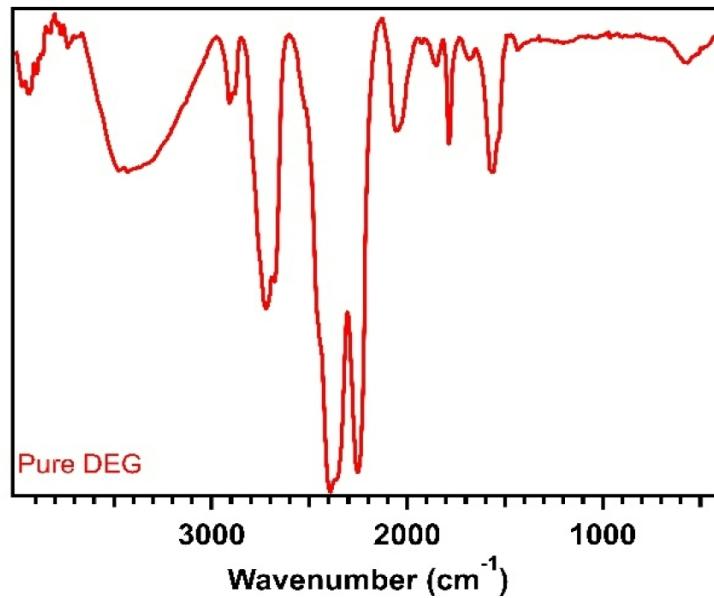
1. Add 1 g of Cu(Mes) to vial
2. Add 3 g of hexadecylamine to vial, opt.
3. Add 20 mL of polyol solvent
4. Select “Cu NP” program on CEM Discover microwave

FTIR of Pure Glycols

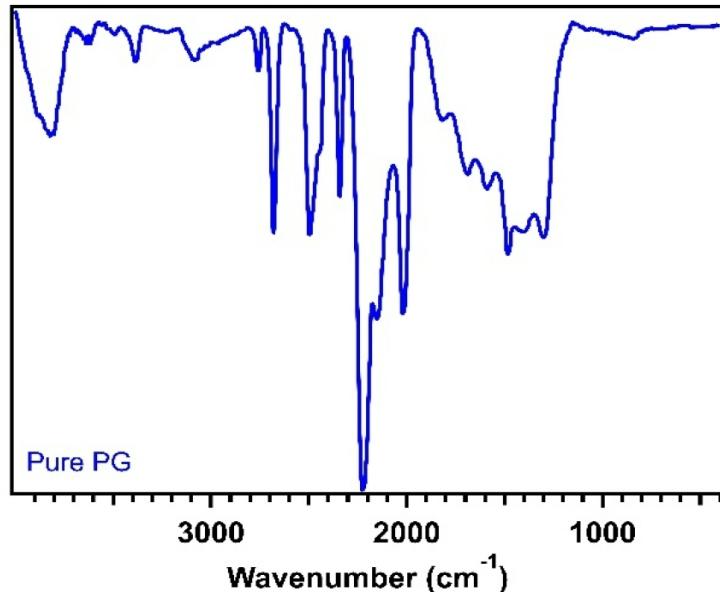
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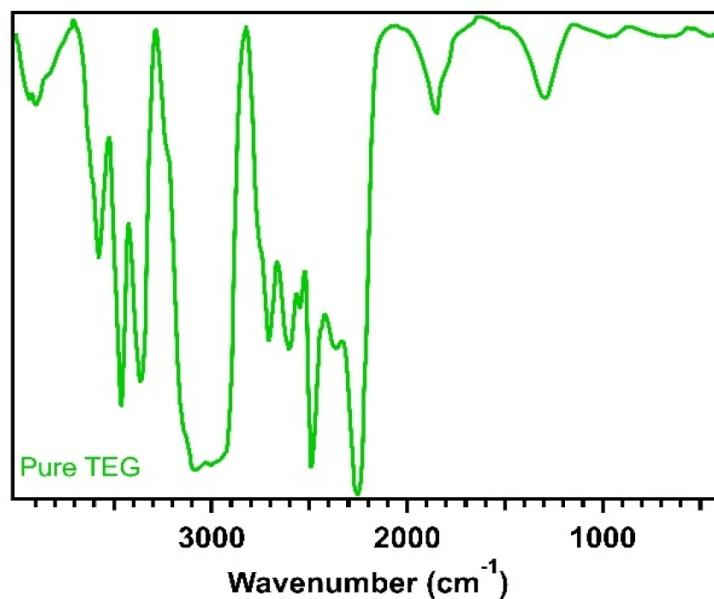


Figure A2. FTIR spectra of pure ethylene glycol (EG), pure diethylene glycol (DEG), pure propylene glycol (PG), and pure tetraethylene glycol (TEG).

TGA of Pure Glycols and HDA

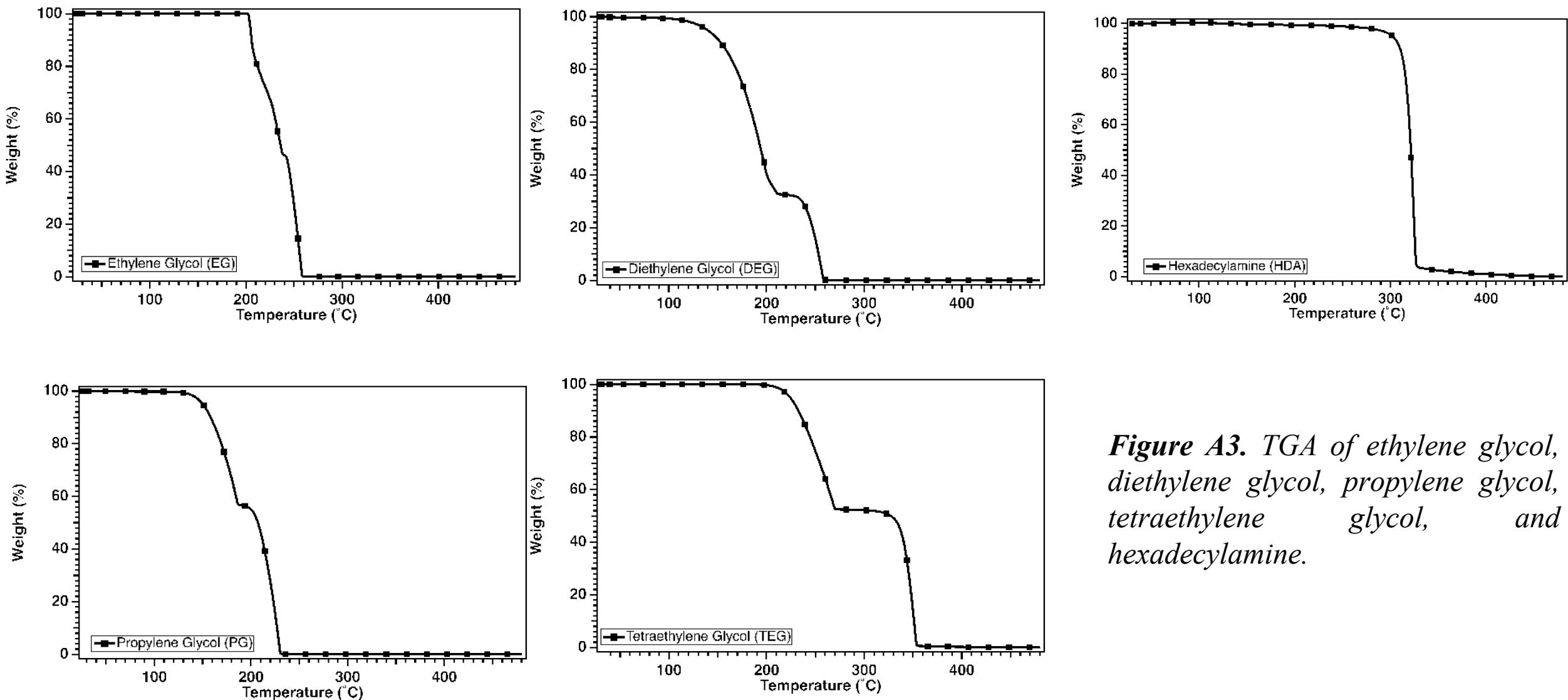
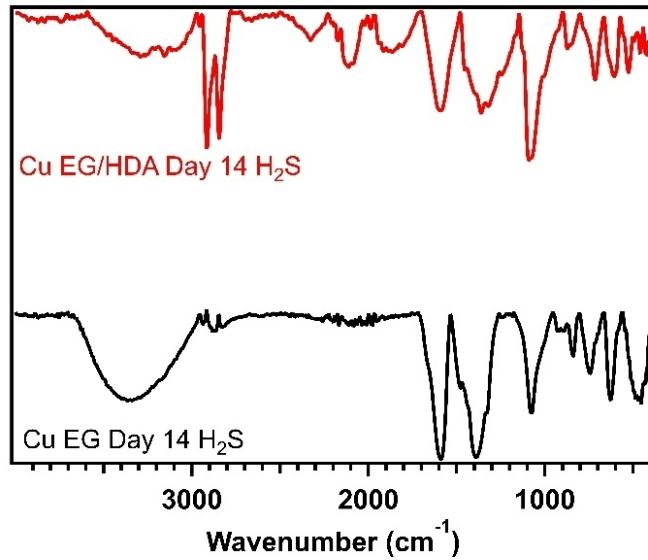


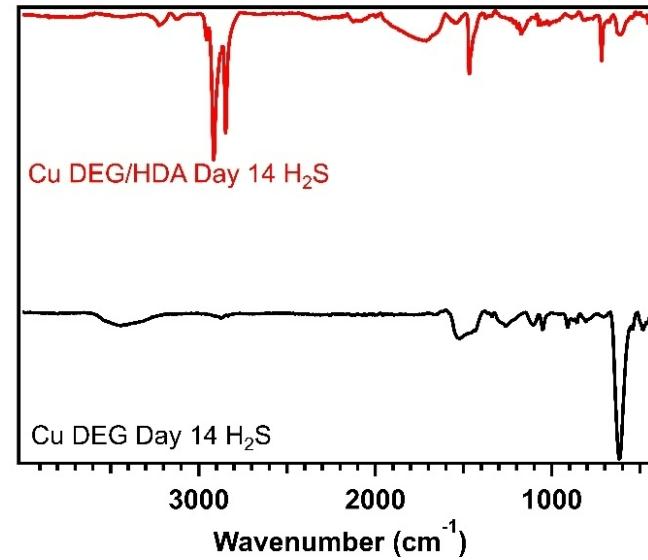
Figure A3. TGA of ethylene glycol, diethylene glycol, propylene glycol, tetraethylene glycol, and hexadecylamine.

FTIR of Glycol vs. Glycol/HAD After 14 Days in H_2S

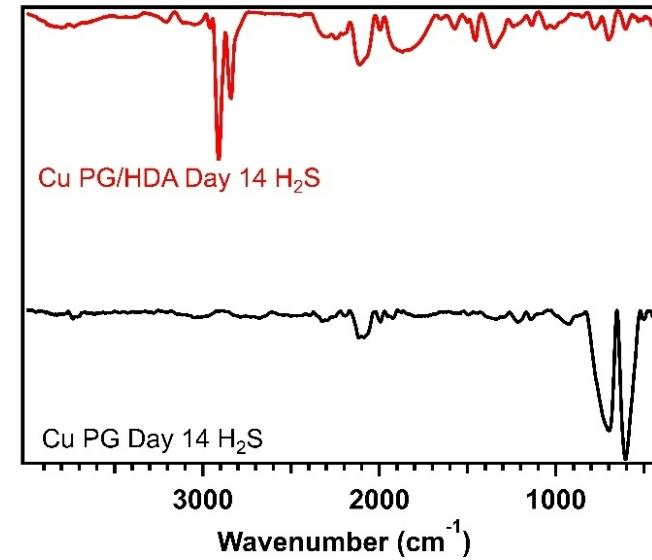
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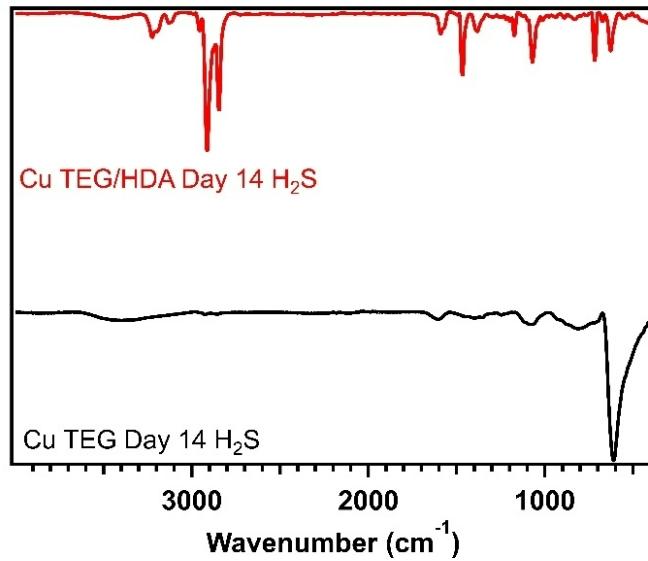
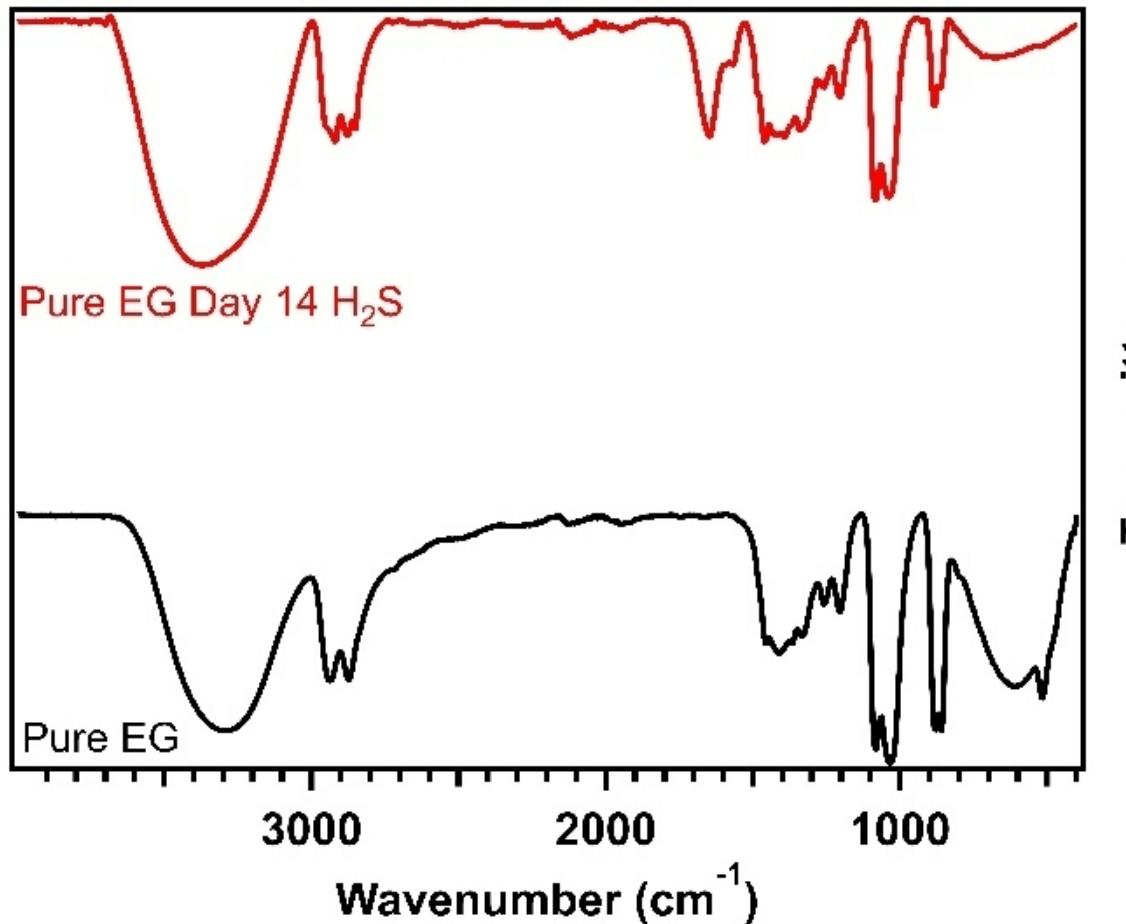


Figure A4. FTIR comparison of polyol vs polyol/HDA after 14 days in 10 ppm H_2S /50% relative humidity environment

FTIR of Pure EG & Pure HDA Before & After H_2S Exposure

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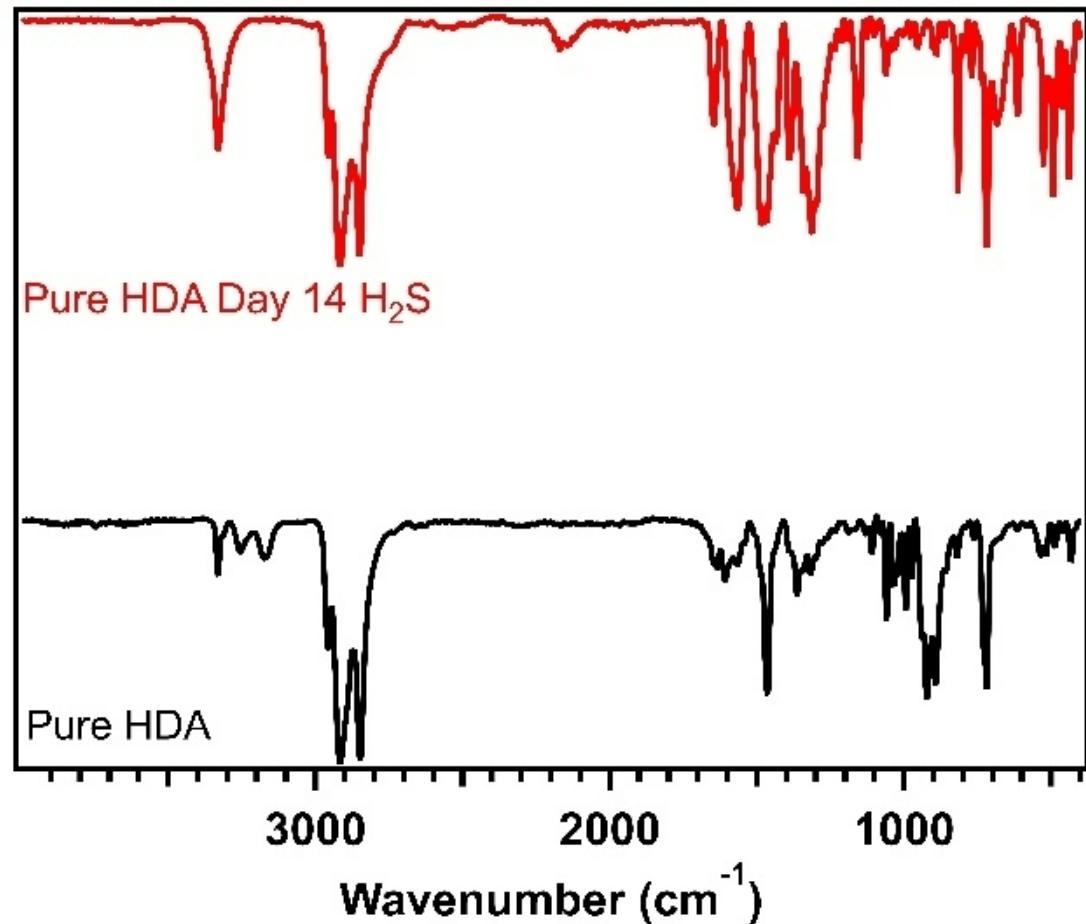


Figure A5. FTIR spectra of (a) pure ethylene glycol and (b) pure hexadecylamine before and after exposure to 10 ppm $\text{H}_2\text{S}/50\%$ RH.